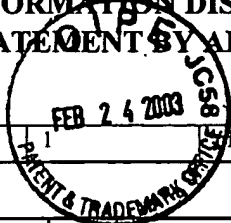


FORM PTO-1449/A and B (Modified)		APPLICATION NO.: 09/720,710	ATTY. DOCKET NO.: M00925.70067.US
INFORMATION DISCLOSURE STATEMENT BY APPLICANT		FILING DATE: July 2, 1999	CONFIRMATION NO.: 5662
		APPLICANT: Vanessa Z.H. Chan et al.	
		GROUP ART UNIT: 1771	EXAMINER: Unassigned
Sheet 1	4		



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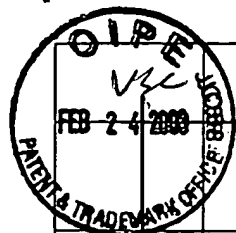
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